Comparison of 3-D Modeling With Experimental Results on Fast Wave Antenna Loading in DIII-D,* R.I. Pinsker, GA; P.M. Ryan, R.H. Goulding, G.R. Hanson, ORNL; D. Milanesio, R. Maggiora, Torino Politecnico; J.C. Hosea, A. Nagy, PPPL; M. Porkolab, MIT; L. Zeng, UCLA – In DIII-D and other tokamaks, with a fixed system voltage limit, the parameter that limits the ICRF power that can be coupled to H-mode plasmas is the antenna loading resistance $R_L$. For a fixed antenna geometry and excitation (phasing), $R_L$ is determined by the electron density profile in the antenna near-field region. Quantitative understanding of the coupling physics is obtained by comparing the resistive ($R_L$) and reactive components of the antenna loading, without and with plasma, to predictions of 3-D models of the antenna and the edge plasma (Microwave Studio and TOPICA). When measured density profiles from reflectometers are used, good agreement between predicted and measured values of $R_L$ is obtained without any adjustable parameters in the model. The improved understanding is applied to enhancement of $R_L$ in advanced scenarios in DIII-D to increase the coupled fast wave power.

*Supported in part by US DOE under DE-FC02-04ER54698, DE-AC05-00OR22725, DE-AC02-09CH11466, DE-FG02-08ER54984.